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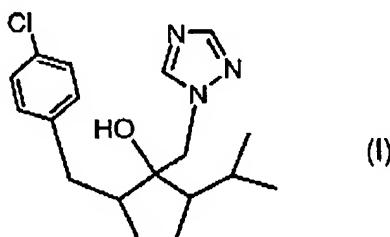
AMENDMENTS TO CLAIMS

This listing of claims will replace all prior versions, and listings, of claims in the present application.

WHAT IS CLAIMED IS:

1. (Currently Amended) Active compound mixture, comprising

a) ipconazole of the formula (I)



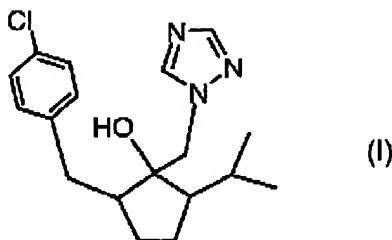
and

b) at least one further fungicidally active compound selected from the group consisting of the metal salts or metal oxides, sulphamides, triazoles, imidazoles, morpholine derivatives, dodemorph and its salts with arylsulphonic acids, benzothiazoles, isothiazolinones, thiocyanates, quaternary ammonium compounds and guanidines, iodine derivatives selected from the group consisting of diiodomethyl-p-tolyl sulphone and 3-iodo-2-propynyl-n-butylcarbamate, phenols, pyridines, methoxyacrylates, and quinolines, and imidazoles selected from the group consisting of clotrimazole, climbazole, imazalil, ketoconazole, prochloraz, and their metal salts and acid adducts.

2. (Cancelled)

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3. (Original) Active compound mixture according to Claim 1, characterized in that the weight ratio of the fungicidally active compound b) to ipconazole a) is from 1:20 to 20:1.
4. (Previously Presented) Active compound mixture according to Claim 1, characterized in that it comprises at least one further active compound c) selected from the group consisting of the insecticides and algicides.
5. (Currently Amended) A process for protecting industrial materials comprising applying thereto an active compound mixture comprising:
 - a) ipconazole of the formula (I)



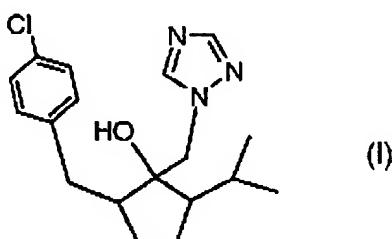
and

b) at least one further fungicidally active compound selected from the group consisting of the metal salts or metal oxides, sulphamides, triazoles, imidazoles, benzimidazoles, ~~morpholine derivatives, dodemorph and its salts with arylsulphonic acids~~, benzothiazoles, isothiazolinones, thiocyanates, quaternary ammonium compounds and guanidines, iodine derivatives selected from the group consisting of diiodomethyl-p-tolyl sulphone and 3-ido-2-propynyl-n-butylcarbamate, phenols, pyridines, methoxyacrylates, and quinolines as micorbiocides.

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6. (Previously Presented) A process according to Claim 5, characterized in that the industrial materials are wood, woodbased materials, plastics, cooling lubricants and coating systems.
7. (Currently Amended) A method for protecting industrial materials against colonization and/or destruction by microorganisms, comprising contacting the microorganism or its habitat with an active compound combination comprising:

- a) ipconazole of the formula (I)



and

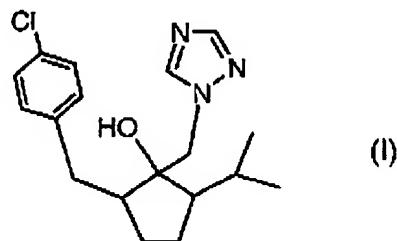
- b) at least one further fungicidally active compound selected from the group consisting of the metal salts or metal oxides, sulphamides, triazoles, imidazoles, benzimidazoles, morpholine-derivatives, dodemorph and its salts with arylsulphonic acids, benzothiazoles, isothiazolinones, thiocyanates, quaternary ammonium compounds and guanidines, iodine derivatives selected from the group consisting of diiodomethyl-p-tolyl sulphone and 3-iodo-2-propynyl-n-butylcarbamate, phenols, pyridines, methoxyacrylates, and quinolines.

8. (Original) Microbical composition, comprising an active compound combination according to Claim 1 and at least one solvent and/or diluent and, optionally processing auxiliaries and, optionally further antimicrobially active compounds.

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9. (Original) Composition according to Claim 8, characterized in that it comprises at least one further antimicrobially active compound from the group of the algicides and/or insecticides.
10. (Currently Amended) An article of matter containing industrial materials, treated with an active compound mixture comprising:

- a) ipconazole of the formula (I)



and

- b) at least one further fungicidally active compound selected from the group consisting of the metal salts or metal oxides, sulphamides, triazoles, imidazoles, benzimidazoles, morpholine derivatives, dodemorph and its salts with arylsulphonic acids, benzothiazoles, isothiazolinones, thiocyanates, quaternary ammonium compounds and guanidines, iodine derivatives selected from the group consisting of diiodomethyl-p-tolyl sulphone and 3-ido-2-propynyl-n-butylcarbamate, phenols, pyridines, methoxyacrylates, and quinolines.

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